

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	455	(substrate or semiconductor or wafer) same (nozzle near4 (center or central or middle)) same (nozzle near4 (array or edge or outer or perimeter))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2007/12/09 20:50
L2	22	(substrate or semiconductor or wafer) same (nozzle near4 (center or central or middle)) same (nozzle near4 (array or edge or outer or perimeter)) and @pd>"20070613"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2007/12/09 20:51
L3	22	(substrate or semiconductor or wafer or TFT) same (nozzle near4 (center or central or middle)) same (nozzle near4 (array or edge or outer or perimeter)) and @pd>"20070613"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2007/12/09 20:56
L4	87	(substrate or semiconductor or wafer or TFT) same (nozzle near4 (center or central or middle)) same (nozzle near4 (array or edge or outer or perimeter))	EPO; JPO; DERWENT	OR	ON	2007/12/09 20:56